

L Number	Hits	Search Text	DB	Time stamp
-	165605	consist\$3 same (nh3 nh?sub.3 ammonia n2 n?sub.2 nitrogen h?sub.2 h2 hydrogen methan ch4 ch?sub.4)	USPAT	2004/06/24 19:15
-	97570	(consist\$3 same (nh3 nh?sub.3 ammonia n2 n?sub.2 nitrogen h?sub.2 h2 hydrogen methan ch4 ch?sub.4)) and consist\$3 near10 (nh3 nh?sub.3 ammonia n2 n?sub.2 nitrogen h?sub.2 h2 hydrogen methan ch4 ch?sub.4))	USPAT	2004/06/24 19:21
-	13832	((consist\$3 same (nh3 nh?sub.3 ammonia n2 n?sub.2 nitrogen h?sub.2 h2 hydrogen methan ch4 ch?sub.4)) and consist\$3 near10 (nh3 nh?sub.3 ammonia n2 n?sub.2 nitrogen h?sub.2 h2 hydrogen methan ch4 ch?sub.4)) and (photoresist resist residu\$2) near15 (nh3 nh?sub.3 ammonia n2 n?sub.2 nitrogen h?sub.2 h2 hydrogen methan ch4 ch?sub.4))	USPAT	2004/06/24 19:17
-	1027	((((consist\$3 same (nh3 nh?sub.3 ammonia n2 n?sub.2 nitrogen h?sub.2 h2 hydrogen methan ch4 ch?sub.4)) and consist\$3 near10 (nh3 nh?sub.3 ammonia n2 n?sub.2 nitrogen h?sub.2 h2 hydrogen methan ch4 ch?sub.4)) and (photoresist resist residu\$2) near15 (nh3 nh?sub.3 ammonia n2 n?sub.2 nitrogen h?sub.2 h2 hydrogen methan ch4 ch?sub.4)) and (257/\$.cccls. 438/\$.cccls. 427/\$.cccls. 156/\$.cccls.))	USPAT	2004/06/24 19:18
-	405	(((((consist\$3 same (nh3 nh?sub.3 ammonia n2 n?sub.2 nitrogen h?sub.2 h2 hydrogen methan ch4 ch?sub.4)) and consist\$3 near10 (nh3 nh?sub.3 ammonia n2 n?sub.2 nitrogen h?sub.2 h2 hydrogen methan ch4 ch?sub.4)) and (photoresist resist residu\$2) near15 (nh3 nh?sub.3 ammonia n2 n?sub.2 nitrogen h?sub.2 h2 hydrogen methan ch4 ch?sub.4)) and (257/\$.cccls. 438/\$.cccls. 427/\$.cccls. 156/\$.cccls.)) and (hole\$1 opening\$1 trench\$2 groove\$1 aperture\$1 recess\$3 cavit\$3 via\$1) same (resit polymer\$2 photoresist residu\$2))	USPAT	2004/06/24 19:20
-	310	(((((consist\$3 same (nh3 nh?sub.3 ammonia n2 n?sub.2 nitrogen h?sub.2 h2 hydrogen methan ch4 ch?sub.4)) and consist\$3 near10 (nh3 nh?sub.3 ammonia n2 n?sub.2 nitrogen h?sub.2 h2 hydrogen methan ch4 ch?sub.4)) and (photoresist resist residu\$2) near15 (nh3 nh?sub.3 ammonia n2 n?sub.2 nitrogen h?sub.2 h2 hydrogen methan ch4 ch?sub.4)) and (257/\$.cccls. 438/\$.cccls. 427/\$.cccls. 156/\$.cccls.)) and (hole\$1 opening\$1 trench\$2 groove\$1 aperture\$1 recess\$3 cavit\$3 via\$1) same (resit polymer\$2 photoresist residu\$2)) and (hole\$1 opening\$1 trench\$2 groove\$1 aperture\$1 recess\$3 cavit\$3 via\$1) near10 (clean\$3 etch\$3 remov\$3))	USPAT	2004/06/24 19:21

-	310	(((((consist\$3 same (nh3 nh?sub.3 ammonia n2 n?sub.2 nitrogen h?sub.2 h2 hydrogen methan ch4 ch?sub.4)) and consist\$3 near10 (nh3 nh?sub.3 ammonia n2 n?sub.2 nitrogen h?sub.2 h2 hydrogen methan ch4 ch?sub.4)) and (photoresist resist residu\$2) near15 (nh3 nh?sub.3 ammonia n2 n?sub.2 nitrogen h?sub.2 h2 hydrogen methan ch4 ch?sub.4)) and (257/\$.cccls. 428/\$.cccls. 427/\$.cccls. 156/\$.cccls.) ) and (hole\$1 opening\$1 trench\$2 groove\$1 aperture\$1 recess\$3 cavit\$3 via\$1) same (resit polymer\$2 photoresist residu\$2)) and (hole\$1 opening\$1 trench\$2 groove\$1 aperture\$1 recess\$3 cavit\$3 via\$1) near10 (clean\$3 etch\$3 remov\$3)) and consist\$3 near10 (nh3 nh?sub.3 ammonia n2 n?sub.2 nitrogen h?sub.2 h2 hydrogen methan ch4 ch?sub.4)	USPAT	2004/06/24 19:22
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